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U.S.	UTILITY	Patent.	Application
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O.I.P.E. MB SCANNED 894

PATENT DATE

APPLICATION NO.	CONT/PRIOR	CLASS	SUBCLASS	ART UNIT	EXAMINER
09/956916		427	1.7.1	1762	
Luc Ouell Jonathan i					

Method of depositing an optical quality silica film by PECVD

TITLE

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	ORIGINAL CROSS REFERENCE(S)																		
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TERMINAL		DRAWINGS		CLAIMS ALLOWED		
DISCLAIMER	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.	
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The term of this patent				NOTICE OF ALLOWANCE MAILED		
subsequent to (date)				•		
has been disclaimed.	(Assistant	Examiner)	(Date)		•	
The term of this patent shall						
not extend beyond the expiration date				ISSUE FEE		
				Amount Due	Date Paid	
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this patent have been disclaimed.	(Legal Instrume	ents Examiner)	(Date)			
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